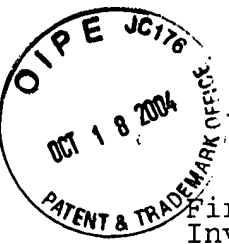


2625
41



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

First Named
Inventor : Stanislav V. Aleshin et al.

Appln. No.: 09/879,664

Filed : June 12, 2001

For : MASK CORRECTION FOR
PHOTOLITHOGRAPHIC PROCESSES

Docket No.: 01-026/L13.12-0149

Group Art Unit: 2625

Examiner: Sheela C.
Chawan

AMENDMENT

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

I HEREBY CERTIFY THAT THIS PAPER IS BEING
SENT BY U.S. MAIL, FIRST CLASS, TO THE
COMMISSIONER FOR PATENTS, P.O. BOX 1450,
ALEXANDRIA, VA 22313-1450, THIS

13 DAY OF October, 2004
David D. Brown
PATENT ATTORNEY

Sir:

This is in response to the Office Action dated July 23,
2004. Please amend the above-identified application as follows:

RECEIVED

OCT 21 2004

Technology Center 2600